



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

2523
#12 / Amot
B
3/21/03
/s

In re Application of :

Jung-Ho Lee, *et al.*

Serial No.: 09/686,624

Filed: October 12, 2000

For: SPIN-ON GLASS COMPOSITION AND
METHOD OF FORMING SILICON
OXIDE LAYER IN SEMICONDUCTOR
MANUFACTURING PROCESS
USING THE SAME

Examiner: Khiem D. Nguyen

Group Art Unit: 2823

Attorney Docket No.: 253/006

Commissioner for Patents
Washington, D.C. 20231

**AMENDMENT AND REQUEST FOR RECONSIDERATION
PURSUANT TO 37 C.F.R. § 1.111**

Sir:

In response to the Office Action mailed December 13, 2002, please amend the
above-identified application as follows:

IN THE CLAIMS:

Kindly amend claims 25 and 27 as follows:

TECHNICAL STAFF 2800

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